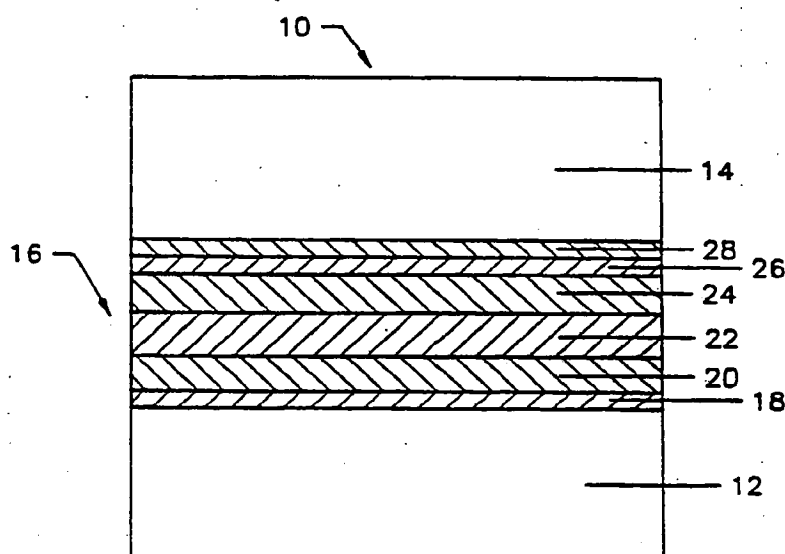




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(54) Title: ELECTROCHROMIC STRUCTURES AND METHODS



(57) Abstract

Electrochromic devices applied to a substrate (12) are disclosed, including an electrochromic electrode layer (20), a counterelectrode layer (24), and an ion-conducting layer (22) sandwiched between those two layers and electrically isolating them from each other, in which the ion-conducting layer (22) is substantially uniform across the substrate and comprises an inorganic superstructure with associated organic material and with a microstructure which facilitates the transfer of ions. Methods for producing these devices are also disclosed, including depositing the ion-conducting layer (22) on the substrate (12) in the form of a solution, and effecting gelation of that solution.

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DESCRIPTIONELECTROCHROMIC STRUCTURES AND METHODSTECHNICAL FIELD

5 The present invention relates to electrochromic devices. More particularly, the present invention relates to monolithic electrochromic devices through which energy, including light, can be transmitted, reflected or absorbed under controlled conditions. More particularly, the present invention
10 relates to methods for the preparation of electrochromic devices.

BACKGROUND ART

 A variety of chromogenic materials are available for controlling the through passage of energy.
15 The various types of such devices operate "chromatically" by producing a change in optical properties in accordance with an applied stimulus or excitation.

 Thus, thermochromic devices change their
20 optical properties in response to changes in temperature. Photochromic devices, on the other hand, change their optical properties in response to changes in the intensity and wavelength of light impinging thereon. In each of these cases, however, the degree of
25 coloration effected is dependent upon external effects, and the user has only limited control thereover. Accordingly, there has been a considerable effort to develop chromogenic materials which undergo reversible coloration induced by applying electric fields or
30 currents, and these are known as electrochromic materials. These solid state inorganic electrochromic layers include those that effect color change due to the dual injection of electrons and ions, typically Group VI-B oxides, such as WO_3 and MoO_3 .

35 These electrochromic devices, while highly desirable particularly for the manufacture of large area electrochromic devices, such as for architectural

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windows, skylights and other transparent-substrate-based products, in order to be of practical use, require sequential combination with other material layers which together form the electrochromic device. These devices thus include layers of the electrochromic material, an ion-conducting material, a counterelectrode material, and electron conducting material layers thereabout. The current state of the art for the formation of these thin film devices, including multi-component oxide material layers, has not been capable of providing truly practicable devices to date. These current film formation methods include vacuum deposition techniques such as sputtering, thermal and electron beam evaporation and plasma-enhanced chemical vapor deposition. These processes, however, are not cost effective in terms of manufacturing operations, particularly for large area electrochromic structures, since they suffer from at least one of the following drawbacks:

- (a) slow deposition rates of the oxide materials required therein;
- (b) non-uniformity of the deposition in terms of both the thickness of the layers, and their chemical compositions;
- (c) a limited control of the chemical composition and microstructure;
- (d) limited selection of starting materials;
- (e) low yield; and
- (f) the need for extensive maintenance.

It has, therefore, been economically difficult to produce electrochromic device panels with surfaces of the type particularly required for architectural windows, skylights and other transparent substrate-based products.

In U.S. Patent No. 4,996,083 electrochromic films are disclosed, and in particular, in which the electrochromic films are produced from solutions. Thus,

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in accordance with this patent, films such as the WO_3 coatings and other metal oxides are produced from an anhydrous transition metal halide and an alcohol.

5 Other electrochromic devices are also known which include an ion-conducting layer which comprises an organic polymer, such as those disclosed in U.S. Patent No. 4,876,628. These devices also have proven unsatisfactory, and uneconomical.

10 The search has, therefore, continued for electrochromic devices and methods for producing them which will facilitate the economical manufacture of large area electrochromic devices and effectively do so at acceptable cost levels.

DISCLOSURE OF INVENTION

15 In accordance with the present invention, these and other objects have now been realized by the invention of an electrochromic device deposited on a substrate comprising an electrochromic layer acting as a first electrode, a counterelectrode layer acting as a
20 second electrode, and an ion-conducting layer between the first and second electrodes, the ion-conducting layer having a substantially uniform thickness and primarily comprising an inorganic material with associated residual hydroxyl and/or organic material,
25 and having a microstructure facilitating the transfer of said ions therethrough. Preferably, the ion-conducting layer is in direct contact with and electrically insulates the first and second electrodes. In accordance with a preferred embodiment of the
30 electrochromic devices of the present invention, the electrochromic layer and/or the counterelectrode layer include residual hydroxyl and/or organic materials therein.

35 In accordance with a preferred embodiment of the electrochromic devices of the present invention, the ion-conducting layer comprises either a lithium ion-conducting layer or a hydrogen ion-conducting layer. In

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the case of the lithium ion-conducting layer, the ion-conducting layer preferably comprises a lithium-based ceramic material.

5 In accordance with a preferred embodiment of the electrochromic devices of the present invention, an electrochromic device applied to a substrate is provided, comprising an electrochromic layer acting as the first electrode, a counterelectrode layer acting as the second electrode, an ion-conducting layer between
10 the first and second electrodes, the ion-conducting layer having a substantially uniform thickness and primarily comprising inorganic material with associated residual hydroxyl and/or organic material and having a microstructure facilitating the transfer of said ions
15 therethrough, and first and second transparent conductive layers in contact with the electrochromic layer and the counterelectrode layer, respectively, for facilitating the flow of electrons therebetween.

In accordance with another embodiment of the present invention, an electrochromic device is provided applied to a substrate and including an electrochromic layer, a counterelectrode layer, and an ion-conducting layer therebetween, with the ion-conducting layer being prepared from the dissolution of at least one metallic
20 organo compound, followed by gelatin of the metallic organo compound, such as a metal or alkali metal alkoxide. Preferably dissolution of the at least one metallic organo compound is carried out in an organic solvent, and preferably at least one of the
25 electrochromic and counterelectrode layers is chemically reduced with a source of charge compensating ions; namely, the ions to be conducted by the ion-conducting layer. In one embodiment at least one of the electrochromic and counterelectrode layers is also
30 produced by dissolution of at least one metallic organo compound in a solvent. In a highly preferred
35

embodiment, the ion-conducting layer is heat treated subsequent to the gelatin step.

5 In accordance with another embodiment of the present invention, a method is provided for the preparation of an electrochromic device deposited on a substrate comprising depositing an electrochromic layer acting as the first electrode on the substrate, depositing a counterelectrode layer acting as the second electrode on the substrate, and depositing an
10 ion-conducting layer between the first and second electrodes by depositing the ion-conducting layer on either electrode in the form of an ion-conducting layer precursor solution and effecting gelation of the ion-conducting layer precursor solution. Preferably,
15 the substrate upon which the electrochromic device is applied is a transparent glass or plastic.

By utilizing the methods and techniques of this invention, it is now possible to adhere these electrochromic materials to relatively large-area
20 substrates, which are preferably transparent in nature.

In accordance with a preferred embodiment of the method of the present invention, the ion-conducting layer precursor solution includes at least one metal in the form of a metal organic or metal salt compound.
25 When a metal organic compound is used it preferably comprises a metal alkoxide, such as an alkali metal alkoxide. In a preferred embodiment, the provision of the electrochromic layer and/or of the counterelectrode layer comprises providing the electrochromic and/or
30 counterelectrode layers in the form of solutions and effecting gelation of these solutions. In both cases, these solutions preferably include at least one metal in the form of a metal organic or metal salt compound, again most preferably a metal alkoxide.

35 In accordance with a preferred embodiment of the method of the present invention, the method includes reducing at least one of the electrochromic and/or

counterelectrode layers by inserting said ions thereinto. In a preferred embodiment a subsequent heat treatment step is then carried out thereon, preferably comprising treating the electrochromic device in a vacuum or in an inert atmosphere, preferably at temperatures above about 100°C, and most preferably above about 150°C.

In accordance with a preferred embodiment of the method of the present invention, the ion-conducting layer is deposited on one of the electrodes on the substrate by depositing an ion-conducting layer precursor solution and effecting gelation thereof by applying the ion-conducting layer precursor solution to the substrate and effecting the condensation and hydrolysis thereof. Preferably, applying the ion-conducting layer precursor to one of the electrodes on the substrate includes removing the substrate from the ion-conducting layer precursor solution at a controlled rate so as to obtain a coating of controlled thickness thereon. In another embodiment, the hydrolysis step comprises exposing the coating of the ion-conducting precursor solution thereon to a controlled environment during evaporation of the solvent. Most preferably, the method includes heating the hydrolyzed ion-conducting layer.

In accordance with this invention, one or more of the electrochromic, counterelectrode and ion-conducting layers, but at least the ion-conducting layer, are produced from a solution, preferably utilizing a sol-gel process. Thus, these one or more thin films are produced by first preparing a mixture of one or more alkoxides in a solvent therefor, and then treating the surface which is to be coated with the alkoxide solution. Application of these films can be accomplished by conventional dipping of the surface, or spin coating techniques. Subsequently, the coated film is then hydrolyzed and condensed while the solvent

evaporates, and then heat treated to obtain a dense film thereon. Preferably, the surface is sequentially coated with the appropriate alkoxide solution to prepare a thin film of controlled thickness thereon, and each such film is hydrolyzed and condensed, and heat treated prior to application of the next such film thereto.

It has been surprisingly discovered that the presence of residual hydroxyl and/or organic or carbon-containing groups therein, in the lithium based ion-conducting layer does not degrade the chromogenic performance of the finished electrochromic device. This is particularly surprising in view of the fact that in such layers, such as lithium silicates and the like, one of ordinary skill in this art would have expected that such fugitive materials would have created problems with the migration of colorant ions therethrough. In this case, however, not only is this not a problem, but the surprisingly significant results and the ability to economically and far more readily produce such a thin film coating of the ion-conducting layer, and ultimately of the multi-layered structure of the electrochromic device hereof, has now been achieved.

BRIEF DESCRIPTION OF THE DRAWINGS

The present invention can be more fully appreciated in connection with the following detailed description, in which reference is made to the drawings in which:

FIG. 1 is a side, elevational, cross-sectional view of an electrochromic device produced in accordance with the present invention; and

FIG. 2 is a side, elevational cross-sectional view of another embodiment of an electrochromic device produced in accordance with the present invention.

BEST MODE OF CARRYING OUT INVENTION

Referring to the Figures, in which like numerals refer to like portions thereof, FIG. 1 is a cross-sectional view of an electrochromic device

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employed in a window 10. In the case of window 10, the substrate 12 is glass. In other applications, however, other transparent substrates can be used, including plastic and the like. In any event, in the case of window 10, the electrochromic device 16 is sandwiched between glass substrate 12 and a second substrate 14, also preferably comprising a glass substrate. In this manner, the window 10 is electrochromic in the sense that the transparency of the area exposed to external illumination or radiation can be controlled electrically or electronically. For this purpose, the occupant of a room or compartment containing the window, such as a skylight or the like, can operate electrical controls in order to achieve a desired degree of darkness or lightness. It will, therefore, be appreciated, that although the invention is illustrated in terms of a window or skylight, it is equally applicable to other areas requiring control of illumination in transmission and/or reflection. Numerous other applications thus include sun glasses, mirrors and the like. In any event, by virtue of the electrical control over transparency, a window, for example, can be in its completely darkened state during the day or even during periods of evening darkness as and when desired.

As is shown in FIG. 1, the window 10 itself includes the electrochromic device 16 comprising a series of layers of thin films deposited on the substrate 12. These include a first transparent conductive layer 18, an electrochromic layer 20, an ion-conducting layer 22, a counterelectrode layer 24, and a second transparent conductive layer 26. The device shown in FIG. 1 can be completed by being adhered to an additional substrate 14 using a convenient medium 28, which can be a laminating transparent adhesive, such as ethylene vinyl acetate or polyvinyl butyral. This adhesive layer can also serve as a vapor barrier.

One or more of layers 18, 20, 22, 24 and 26, but at least ion-conducting layer 22, is applied to layer 20 (or to layer 24, depending upon the sequence adopted for application of these layers) from a solution, preferably using a "sol-gel" technique, employing techniques such as dipping, spinning, roll coating, curtain coating, premetered slot techniques, or the like. Preferably, each of these layers is deposited on the substrate (i.e., on the preceding layer) using this technique. However, it is within the scope of the present invention for layers other than ion-conducting layer 22, and particularly including electrochromic layer 20 and counterelectrode layer 24, to be applied by conventional techniques, such as by the vapor deposition techniques and the like discussed above.

The ion-conducting layer 22 of the present invention is thus a "fast" ion conductor, which allows for easy throughpassage of ions. The ion-conducting layers (22) produced by these sol-gel techniques are believed to thus have a relatively open nature, with the presence of interconnected nanoscale porosity therein. These nonporous gels thus exhibit both high ionic mobility and high degrees of ion concentration therein.

The transparent conductive layers 18 and 26 are transparent yet conductive thin films which preferably have a low sheet resistance, such as less than about 10 ohms per square, and preferably less than about 5 ohms per square. Preferably, tin doped indium oxide (ITO) coatings are used, although other such coatings can be utilized, including fluorine-doped tin oxide, doped zinc oxide, and the like. These conductive films are connected to a conventional DC current source (not shown) in a conventional manner.

The active electrochromic layer 20 is then applied to layer 18 on substrate 12. The electrochromic layer changes color in a completed device when electrical current is applied thereto. It is thus

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normally transparent or colorless, but when reduced by the insertion of an electron and charge-compensating ion becomes colored due to a change in absorption, reflectance, or a combination thereof. (Therefore, these ions can also be referred to as "colorant" ions.) Thus, the ability of this layer to change its transparency and transmit light is a direct function of the number of guest species, such as lithium or hydrogen ions, in that layer. The preferred electrochromic layer 20 is tungsten oxide (WO_3), but other such electrochromic layers can include various transition metal oxides, such as niobium oxide, titanium oxide, molybdenum oxide, nickel oxide, iridium oxide, and solid solution mixtures of such oxides.

The ion-conducting layer 22 is then applied to layer 20. This layer is transparent in the visible range, and preferably has a high electrical resistivity and high ionic conductivity. Thus, this electrically insulating ion-conducting layer 22 electrically isolates the electrochromic layer 20 from the counterelectrode layer 24. The ion-conducting layer 22 allows ions but not electrons to pass through it, and thus provides a device with "memory." The ion-conducting layer of the present invention, formed in accordance with the method of the present invention from a solution as discussed below, primarily comprise a layer of inorganic material which is prepared from and includes residue from organic constituents. Thus, the ion-conducting layer 22 is primarily exclusively inorganic material, possibly with a small amount of the hydroxyl and/or organic residue, primarily the residue of the alkoxide groups used to prepare this layer and/or of residual solvent, associated with the inorganic material thereof. In general, there will be less than about 1 wt.% of any such hydroxyl and/or organic residue. The precise amount will be calculable by one of ordinary skill in this art based upon his knowledge of the surface area,

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and the deposition conditions for the particular thin film in question. The thin films of this invention are not generally extremely high surface area sol-gel systems, and can thus have surface areas as low as about
5 $1 \text{ m}^2/\text{gram}$, although higher surface area films can be utilized.

The finished layer 22 itself comprises a silicate-based structure, which again is capable of conducting the ions, preferably lithium ions or protons,
10 used in connection with the electrochromic devices hereof. Suitable ion conductors particularly adapted for lithium ion transmission include lithium silicate, lithium aluminum silicate, lithium aluminum borate, lithium borate, lithium zirconium silicate, lithium
15 niobate, lithium borosilicate, lithium phosphosilicate, lithium nitride, lithium aluminum fluoride, and other such lithium-based ceramic materials. As indicated, other suitable ion-conducting electrolytes can be used, such as silicon dioxide or tantalum oxide, for proton
20 (hydrogen) based electrochromic devices.

The ion-conducting layer 22 hereof, because of the solution-based methods used for the preparation thereof, can have a carefully controlled thickness. It is, therefore, possible to produce such layers of the
25 desired thickness (i.e., thick enough to provide the required electrical insulation), but of no greater than such desired thickness, so as to avoid the need to apply thicker than necessary ion-conducting layers. These thicker layers can thus be overly cumbersome and
30 expensive, and can also slow down the "switching" time, or rate at which the electrochromic devices hereof can convert to a tinted (reduced) or bleached condition. In particular, these ion-conducting layers can thus preferably be between about 200 to 5,000 Angstroms
35 thick, and more preferably be between about 500 to 2,000 Angstroms thick. This can be contrasted, for example, to many of the prior art devices which employ a

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polymeric electrolyte layer in the form of a laminate, and thus have a far greater thickness; e.g., on the order of about 10 microns or more.

The next layer applied to ion-conducting layer 22 is the counterelectrode layer 24. The counterelectrode layer, which can be electrochromic in that it may change color when electrical current is applied thereto, is not necessarily electrochromic. In any event, the purpose of the counterelectrode layer is primarily to store the colorant ions, such as lithium or hydrogen ions, when not employed in the electrochromic layer 20. When the counterelectrode materials are also electrochromic in that they change their shade or transparency as atoms move in and out of them, these materials may act to complement the coloration of the electrochromic layer 20. Particularly preferred such materials for the counterelectrode layer include vanadium pentoxide (V_2O_5), niobium oxide, indium oxide, nickel oxide, nickel hydroxide, iridium oxide, cobalt oxide, molybdenum oxide, and mixtures of these materials, such as chromium-vanadium oxide and the like. Thus, in a preferred embodiment, the counterelectrode layer has a general formula $A_x(MO)$, where MO is a mixture of vanadium oxide or chromium oxide together or with oxides of an additional material, such as niobium, titanium, tantalum or the like. A is an atom identical to the insertion or colorant ion in the electrochromic layer, and the transported ion through the ion-conducting layer. These mixed oxides have superior reduced state visible light transmission as compared to V_2O_5 and may be oxidized and reduced with, for example, Li^+ insertion ions many times in a reversible manner without loss of activity or without change in optical properties.

Finally, another transparent conductive material layer 26 in accordance with the present

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invention, again such as the indium tin oxide coatings and the like discussed above, is then deposited thereon.

Prior to completion of the window 10, it is necessary to introduce the colorant ion into the device, and most particularly into at least one of the electrochromic layer 20 and/or counterelectrode layer 24. In effect, at least one of these two layers is chemically reduced by the insertion of colorant atoms, such as lithium or atomic hydrogen thereinto, unless there is already a source of these atoms within one of these constituents. Thus, the electrochromic and/or counterelectrode layers can be deposited in such a reduced state. This can be done, for example, by direct vapor deposition of $\text{Li}_x\text{V}_2\text{O}_5$ (or another counterelectrode), its reduction by elemental Li in a separate step, or electrochemical reduction of the counterelectrode layer in an electrolytic solution of Li^+ . Similarly, the Li can also be initially introduced into the electrochromic layer (e.g., WO_3) using similar methods.

If the electrochromic and/or counterelectrode layers are to be reduced subsequent to their deposition, this can be accomplished in a conventional manner by treatment with an appropriate reducing agent, such as n-butyl lithium in the case of lithium ions, or sulfuric acid in the case of hydrogen ions.

In a preferred embodiment of the invention, the completed device is subjected to a heat treatment process. This heat treatment procedure is carried out subsequent to fabrication of the device; i.e., after the electrochromic layers have been deposited and at least one of the electrochromic layer and/or counterelectrode layers has been reduced in the manner discussed above. Carrying out the heat treatment process at this point has a positive effect on the switching characteristics of the electrochromic devices hereof; i.e., between its bleached and reduced states, as well as upon the overall

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optical properties thereof. The treatment itself preferably occurs in a vacuum or an inert atmosphere, and preferably occurs at temperatures above about 100°C, preferably above about 150°C, and most preferably between about 200 and 300°C.

Turning to FIG. 2, another embodiment of the electrochromic device of the present invention is shown. In this case, in which all of the like reference numerals refer to like portions thereof, upon the substrate 12, preferably glass, are applied the same first conductive oxide layer 18, electrochromic layer 20, ion-conducting layer 22, and counterelectrode layer 24, as discussed above. However, in this case, instead of the second conductive oxide layer 26, as shown in FIG. 1, there is applied a thin metal layer 32, preferably silver or the like. Furthermore, intermediate the counterelectrode layer 24 and the silver layer 32 is applied a thin primer layer for the silver comprising a thin metal layer or barrier layer preventing direct contact between the silver layer 32 and the counterelectrode layer 24, such as a thin layer of copper, titanium, nickel or the like. In this case, it is then essential to apply an optical tuning layer 34 thereto. Optical tuning layer 34, which can comprise a metal oxide layer, such as indium tin oxide, zinc oxide, zirconium oxide or the like, is provided in accordance with the disclosure of co-pending Application Serial No. 07/754,650 filed on September 4, 1991.

As noted above, in accordance with this invention, at least the ion-conducting layer 22, and possibly also each of the additional layers of the electrochromic devices of the present invention, are applied by a method which employs a solution; i.e., as opposed to the prior deposition techniques, such as sputtering and the like. In the case of deposition of a metal oxide, such a layer can be deposited employing this technique by providing the metal in the form of an

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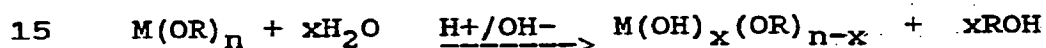
alkoxide in an organic solvent, such as an alcohol. In particular, the alcohol used can be a C_1 to C_5 alcohol, and most preferably a C_1 to C_3 alcohol. Thus, the preferred alcohols are methanol, ethanol, propanol, isopropanol, and mixtures thereof. The butyl and pentyl alcohols are broadly operable, but the higher alcohols, and sometimes even the butyl and pentyl alcohols will sometimes result in metal precipitates. In some cases, other protic or aprotic organic solvents can be used, such as formamide, dimethylformamide, or tetrahydrofuran. In the case of the electrochromic layer and/or the counterelectrode layer, the solution technique disclosed in U.S. Patent No. 4,996,083, particularly as set forth therein from column 3, lines 1 through 68, the disclosure of which is incorporated herein by reference thereto, can be employed. In the case of the ion-conducting layer, there are a number of alternatives. It must first be noted that for the purposes of this invention, the term "metal" includes all of the conventional metallic compounds, but also those "metals" of Groups III-A and IV-A of the Periodic Table of the Elements, such as silicon, boron, aluminum, tin, and the like. Therefore, throughout this specification, and in the claims hereof, this term will have such an inclusive meaning. In any event, the metal component can be provided in the form of a metal organic compound, such as a metal alkoxide or the like, including the alkali metal alkoxides or a metal aryloxy. Thus, the metal or alkali metal alkoxides can include the C_1 to C_3 alkoxides, primarily the methoxides and ethoxides, since longer chain alkoxides tend to present steric problems. The aryloxides can include the phenoxides and the like. Furthermore, in the case of metals such as silicon, organic tetra-alkoxy silanes, such as tetraethyl-orthosilicate, are preferred. However, it is possible to use organic tri- or di-alkoxy silanes, of the formulae $R'Si(OR)_3$ or $R'_2Si(OR)_2$ in which R' is a non-

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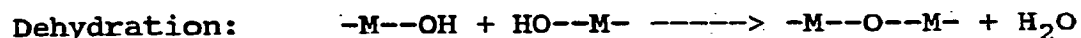
hydrolyzable organic substrate. These compounds can include, for example, tetra-n-butoxy silane and tetra-n-propoxy silane. In general, most sol-gel materials are polymeric metal oxides. Thus, the initial reactants or precursors for these are most often metal alkoxides which are converted by hydrolysis and condensation sequentially into a sol (a suspension or dispersion of discrete colloidal particles) and into a gel (a colloidal or polymeric solid containing a fluid component).

Thus, a typical metal oxide gel is prepared from a metal alkoxide in the following manner:

Hydrolysis reaction:



Condensation Reactions:



While this example has employed water as the conventional initiator for the hydrolysis reaction hereof, it will be understood that other sources of hydroxyl ions could be substituted for water. For example, one might utilize polyethylene glycol compounds including at least one hydroxyl group per molecule for such purposes, and in that case potentially employ a non-aqueous medium.

Following transition of the solution into the sol-gel state, careful thermal processing then leads to the stabilized porous glass monolith. The most common sol-gel system are based on silica, and hydrolyzed tetraethylorthosilicate (TEOS = $Si(OC_2H_5)_4$) has been used as an adhesive, for example. Dependent upon the amount of solvent and catalyst present, hydrolysis and the related reactions can go to completion with, in the case of hydrolysis, the -OR groups replaced by the hydroxyl groups, -OH. In addition to the metal organo

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compounds, inorganic precursors can also be hydrolyzed in this manner.

5 Upon partial or full hydrolysis, the molecules are then able to link together in a condensation reaction liberating small scale molecules such as water and/or alcohol. The reaction can then continue to build molecules. Condensation that takes place then results in a colloidal cross-linked polymer known as a sol.

10 Colloidal sols are particulate where non-polymeric solid particles are dispersed into a fluid. Particulate silica sols are typically formed in aqueous solutions. Polymeric silica sols, on the other hand, are obtained from the hydrolysis of alkoxides in largely non-aqueous solutions. Silica tends to form polymeric
15 sols, but most other oxides form particulate sols.

In substantially non-aqueous solutions of alkoxides and alcohol, the solubility of the solid phase is limited, and the condensation reaction is essentially irreversible. When a molecule thus reaches macroscopic
20 dimensions and extends throughout the solution, a gel point is reached when the last bond is formed to complete the molecule. The resulting gel has a continuous gelatin phase enveloping a continuous liquid phase. The continuity of this skeleton provides
25 elasticity. A polymeric gel is formed from particulate sols when attractive dispersion forces cause the particles to adhere and form a network.

In general, a gel is a two-phase semi-solid containing liquid in a fluid phase of colloidal
30 dimensions. The type of bonding is not characteristic, since the bonds may be reversible or permanent, as in polymeric systems. When the gel process begins, particulate aggregates are formed that grow, impinging on one another and then linking together by percolation.
35 In the other gel point, bonds form at random. Gelation after casting produces a monolith, while gelation after

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coating on a substrate with rapid evaporation of solvent produces films.

While gels are generally amorphous, they may crystallize on heating at high temperatures by the collapse of pores. When amorphous gels are sufficiently heated, the transport of atoms is by viscous flow and the result is viscous sintering. In crystalline materials, the sintering is by relatively slow diffusion.

In the sol-gel process of the present invention, the process proceeds in a number of stages. In the first stage, a solution of the mixture is produced which can include one or more alkoxides and/or metallic compounds therein.

In the solution-based or sol-gel process for preparation of the thin films of the present invention, the process is initiated by the dissolution of the ingredients including one or more alkoxides or their equivalents and/or metallic compounds. The next step is coating of the substrate or of a layer of material already deposited upon the substrate, such as by spin coating, dipping or the like, preferably on a transparent glass or plastic substrate. The next step constitute simultaneous hydrolysis and drying. The hydrolysis step preferably comprises evaporation of the solvent in a controlled environment. Thus, an environment of controlled humidity conditions can be utilized. On the other hand, this environment can be controlled by regulating the partial pressure of the solvent. In either of these cases, the critical element is the pressure of water (or possible another hydroxyl-containing hydrolysis initiator as discussed above). While it is theoretically possible to add the hydroxyl-containing compound, such as water, to the solution itself, this procedure is generally not useful because of the instability of the solutions in question. Thus, the preferred method hereof includes creation of a film

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and then effecting hydrolysis by contact with water, such as in a controlled humidity environment and the like. As noted above, the partial pressure of the solvent might also be controlled in that environment to further control the rate of hydrolysis. Finally, heat treatment is effected in order to eliminate solvents and water and to promote film condensation. In any event, upon completion of the gelatin process, the ion-conducting layer (or other such layer if so prepared) consists of an inorganic porous structure, but with residual hydroxyl groups and/or organic materials, such as carbon constituents, associated therewith. Again, the presence of these residual organics has not been found to have any adverse effect upon the nature and operation of these electrochromic devices.

By producing at least the ion-conducting layer of the present devices in accordance with this technique, particularly as compared to the prior deposition of ion-conducting layers by sputtering or the like, and/or the use of various polymeric electrolyte systems, it is possible to create interconnected networks of channels to yield higher ionic conductivities therein. Furthermore, applicants have obtained a highly uniform coating, since the entire surface is wetted by this technique, particularly as compared to prior techniques such as sputtering and the like. Therefore, the interface between this ion-conducting layer and adjacent layers will be highly diffuse, whereas with conventional thin film techniques a sharp or non-diffuse interface will be produced. In addition, a high film formation rate and a uniform chemical composition can be obtained hereby. Also, high process temperatures are not required in accordance with this invention. In fact, lithium-based electrochromic devices can be prepared in accordance with the present invention at temperatures lower than about 200°C.

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In order to more fully appreciate the present invention, reference is made to the following examples thereof.

Example 1

5 An electrochromic layer 20 in accordance with the present invention can be produced by dissolving a metal alkoxide, such as tungsten or molybdenum alkoxide, in an organic solvent such as an alcohol. The solvent can then be evaporated in a controlled atmosphere to
10 produce a condensed coating. The coating can then be heated to convert it to a hardened layer, such as tungsten oxide or molybdenum oxide.

Example 2

15 Another method of producing an electrochromic layer of tungsten oxide in accordance with the present invention is by employing tungsten ethoxide ($W(OC_2H_5)_5$) in an amount of 200 cc of dry ethanol. The solution can, if necessary, be further diluted with ethanol, and then coated upon a substrate with a controlled
20 thickness. The coating can then be hydrolyzed and dried, leaving a residue which is then heated at a rate of about 50°C per minute for about 10 minutes to below 500°C. The substrate can then be baked at this temperature for an additional 20 minutes, and then
25 cooled at a similar rate of about 50°C per minute. A clear, hardened, transparent layer of tungsten oxide can then be obtained.

Example 3

30 In order to manufacture an ion-conductor layer 22 in accordance with the present invention, a metal alkoxide, nitrate or halide, such as a lithium alkoxide (e.g., lithium methoxide), lithium nitrate or lithium chloride can be dissolved in an organic solvent to which is added TEOS. If a second component is to be
35 included in the layer, such as zirconium, aluminum or titanium, an alkoxide and/or a metallic salt of zirconium, aluminum or titanium can then be added, and

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the solution maintained at suitable temperatures. The coating step can then be carried out, after which the solvent can be evaporated in the presence of moisture to produce the hydrolyzed gel. Finally, the gel can be heated, preferably at temperatures ranging up to about 300°C, in order to produce a hardened layer of lithium silicate or a lithium-containing glass.

Example 4

A counterelectrode layer 24 can be produced in accordance with the sol-gel procedures hereof by dissolving a metal alkoxide such as vanadium isopropoxide in an organic solvent such as an alcohol. The coating can then be obtained from this solution, hydrolyzed and then heat treated to produce a hardened film of vanadium oxide.

Example 5

Another counterelectrode layer 24 in accordance with this invention can be prepared by dissolving a mixture of vanadium triisopropoxide, oxide and chromium isopropoxide in methanol. The substrate can then be dipped into the solution at a controlled rate in a controlled atmosphere. After hydrolyzing and heat treating, a dense film of vanadium and chromium oxide can be obtained.

Example 6

An electrochromic device is produced in accordance with the method of the present invention by sequential deposition of the layers of the electrochromic device onto a glass substrate. Thus, the substrate can first be coated with fluorine doped tin oxide by chemical vapor deposition of tin tetrachloride, 1,1 difluoroethane, and water in a nitrogen atmosphere, at 590°C. Electrochromic layer 20 can then be deposited by depositing a tungsten oxide coating onto the substrate by reactive sputtering of tungsten in the presence of argon and oxygen. Subsequently, the ion-conducting layer of the present invention can be

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applied from a solution in accordance with the method of this invention by mixing lithium methoxide with TEOS in ethanol, and then coating the substrate at a controlled rate by dipping in this solution. The coating layer can then be hydrolyzed and heat treated at a temperature of 300°C to produce a hardened layer of lithium silicate. A counterelectrode layer 24 can then be applied thereto by applying a vanadium oxide layer by reactive sputtering of vanadium in the presence of argon and oxygen. The vanadium oxide layer can then be reduced by the application of lithium ions thereto. Subsequently, another layer of transparent conductive oxide can be applied by sputtering indium tin oxide. The entire device can then be heat treated in a vacuum at 250°C, and then laminated to a secondary glass substrate utilizing a layer of ethylene vinyl acetate.

Although the invention herein has been described with reference to particular embodiments, it is to be understood that these embodiments are merely illustrative of the principles and applications of the present invention. It is therefore to be understood that numerous modifications may be made to the illustrative embodiments and that other arrangements may be devised without departing from the spirit and scope of the present invention as defined by the appended claims.

INDUSTRIAL APPLICABILITY

An electrochromic device is provided for use in architectural windows, skylights and other such transparent substrate-based product, whereby energy, including light, can be transmitted, reflected or absorbed thereby under controlled conditions. These devices thus permit these products to undergo reversible coloration which is induced by the application of an electric field or current so as to improve energy efficiency and the like.

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CLAIMS

1. An electrochromic device applied to a substrate (12) comprising an electrochromic layer (20) acting as a first electrode, a counterelectrode layer (24) acting as a second electrode, and an ion-conducting layer (22) between said first and second electrodes, characterized by said ion-conducting layer (22) having a substantially uniform thickness and comprising inorganic material with associated residual hydroxyl and/or organic material, and having a microstructure facilitating the transfer of said ions therethrough.
2. The electrochromic device according to claim 1, characterized in that said ion-conducting layer (22) has a substantially uniform thickness of between about 200 and 5,000 Angstroms.
3. The electrochromic device according to claim 1 or 2, characterized in that said ion-conducting layer (22) has a substantially uniform thickness of between about 500 and 2,000 Angstroms.
4. The electrochromic device according to claim 1, 2 or 3, characterized in that said residual hydroxyl and organic material is present in an amount of less than about 1 wt.%.
5. The electrochromic device according to any one of the preceding claims, characterized in that said ion-conducting layer (22) is in direct contact with and electrically insulates said first and second electrodes (20, 24).
6. The electrochromic device according to claim 1, 2 or 3, characterized in that said electrochromic layer (24) includes residual hydroxyl and/or organic materials.
7. The electrochromic device according to claim 1, 2 or 3, characterized in that said counterelectrode layer (24) includes residual hydroxyl and/or organic materials therein.

8. The electrochromic device according to any one of the preceding claims, characterized in that said ion-conducting layer (22) comprises a lithium-ion-conducting layer.

5 9. The electrochromic device according to claim 8, characterized in that said lithium-ion-conducting layer (22) comprises a lithium-based ceramic material.

10 10. The electrochromic device according to claim 9, characterized in that said lithium-based ceramic material is selected from the group consisting of lithium silicate, lithium borosilicate, lithium aluminum silicate, lithium niobate, lithium nitride, and lithium aluminum fluoride.

15 11. The electrochromic device according to claim 1, 2 or 3, characterized in that said ion-conducting layer (22) comprises a hydrogen ion-conducting layer.

20 12. The electrochromic device according to claim 11, characterized in that said hydrogen ion-conducting layer comprises silicon dioxide.

13. The electrochromic device according to any one of the preceding claims, characterized in that said substrate (12) comprises glass.

25 14. The electrochromic device according to claim 1, 2 or 3, characterized in that said electrochromic layer (20) is selected from the group consisting of tungsten oxide, niobium oxide, titanium oxide, molybdenum oxide, nickel oxide, iridium oxide, and mixtures thereof.

30 15. The electrochromic device according to claim 1, 2 or 3, characterized in that said counterelectrode layer (24) is selected from the group consisting of vanadium pentoxide, niobium oxide, indium oxide, nickel oxide, cobalt oxide, molybdenum oxide, and mixtures thereof.

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16. The electrochromic device according to claim 1, 2 or 3, characterized in that said ion-conducting layer (22) is prepared from the dissolution of at least one metallic organo compound, followed by gelation of said metallic organo compound.

17. The electrochromic device according to claim 16, characterized in that said metallic organo compound comprises a metal alkoxide.

18. The electrochromic device according to claim 16, characterized in that said metal alkoxide comprises an alkali metal alkoxide.

19. The electrochromic device according to claim 16, 17 or 18, characterized in that at least one of said electrochromic layer (20) and said counterelectrode layer (24) is chemically reduced with a source of charge compensating ions, said charge compensating ions comprising the ions to be conducted by said ion-conducting layer (22).

20. The electrochromic device according to claim 16, 17 or 18, characterized in that at least one of said electrochromic layer (20) and said counterelectrode layer (24) is produced by dissolution of at least one metallic organo compound in a solvent.

21. The electrochromic device according to claim 16, 17 or 18, characterized in that said electrochromic layer (20) is selected from the group consisting of tungsten oxide, niobium oxide, molybdenum oxide, nickel oxide, iridium oxide, and mixtures thereof.

22. The electrochromic device according to claim 16, 17 or 18, characterized in that said counterelectrode layer (24) is selected from the group consisting of vanadium pentoxide, niobium oxide, indium oxide, nickel oxide, cobalt oxide, molybdenum oxide, and mixtures thereof.

23. The electrochromic device according to claim 16, 17 or 18, further characterized by first and

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second transparent conductive layers (18, 26) in contact with said electrochromic layer (20) and said counterelectrode layer (24), respectively.

5 24. The electrochromic device according to claim 16, 17 or 18, further characterized by heating said ion-conducting layer (22) subsequent to said gelation step.

10 25. An electrochromic device applied to a substrate (12) comprising an electrochromic layer (20) acting as a first electrode, a counterelectrode layer (24) acting as a second electrode, an ion-conducting layer (22) between said first and second electrodes, characterized by said ion-conducting layer (22) having a substantially uniform thickness and comprising inorganic
15 material with associated residual hydroxyl or organic material, and having a microstructure facilitating the transfer of said ions therethrough, and first and second transparent conductive layers (18, 26) in contact with said electrochromic layer (20) and said counterelectrode
20 layer (24), respectively, for facilitating the flow of electrons therebetween.

25 26. The electrochromic device according to claim 25, characterized in that said ion-conducting layer (22) has a substantially uniform thickness of between about 200 and 5,000 Angstroms.

30 27. The electrochromic device according to claim 25 or 26, characterized in that said ion-conducting layer (22) is in direct contact with and electrically insulating said first and second electrodes (20, 24).

28. The electrochromic device according to claim 25, characterized in that said substrate (12) comprises glass.

35 29. The electrochromic device according to claim 25 or 26, characterized in that said first and second conductive layers (18, 26) comprise conductive metal oxides.

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30. The electrochromic device according to claim 25 or 26, characterized in that at least one of said first and second transparent conductive layers (18, 26) comprises a thin metal layer and an optical tuning layer.

31. The electrochromic device according to claim 30, characterized in that said optical tuning layer comprises a metal oxide layer.

32. The electrochromic device according to claim 29, characterized in that said conductive metal oxides comprise tin doped indium oxide.

33. A method for the preparation of an electrochromic device deposited on a substrate (12) comprising depositing an electrochromic layer (20) acting as a first electrode on said substrate, depositing a counterelectrode layer (24) acting as a second electrode, and depositing an ion-conducting layer (21) between said first and second electrodes characterized by depositing said ion-conducting layer (21) on said first or second electrode (20, 24) in the form of an ion-conducting layer precursor solution and effecting gelation of said ion-conducting layer precursor solution.

34. The method according to claim 33, characterized in that said substrate (12) comprises glass.

35. The method according to claim 33 or 34, characterized in that said ion-conducting layer precursor solution includes at least one metal in the form of a metal organic or a metal salt compound.

36. The method according to claim 35, characterized in that said metal organic compound comprises a metal alkoxide.

37. The method according to claim 35, characterized in that said ion-conducting layer (22) comprises a lithium ion-conducting layer.

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38. The method according to claim 37, characterized in that said ion-conducting layer precursor solution includes an alkali metal in the form of an alkali metal alkoxide compound.

5 39. The method according to claim 38, characterized in that said alkali metal comprises lithium.

10 40. The method according to claim 37, characterized in that said lithium-ion-conducting layer comprises a lithium-based ceramic material.

41. The method according to claim 33, 34 or 35, characterized in that said ion-conducting layer (22) is in direct contact with and electrically insulates said first and second electrodes (20, 24).

15 42. The method according to claim 33, 34 or 35, characterized in that said depositing of said electrochromic layer (20) comprises depositing said electrochromic layer in the form of an electrochromic layer precursor solution and effecting gelation of said electrochromic layer precursor solution.

20 43. The method according to claim 33, 34 or 35, characterized in that said depositing of said counterelectrode layer (24) comprises depositing said counterelectrode layer in the form of a counterelectrode layer precursor solution and effecting gelation of said counterelectrode layer precursor solution.

30 44. The method according to claim 42, characterized in that both said ion-conducting layer precursor solution and said electrochromic layer precursor solution include at least one metal in the form of a metal organic or a metal salt compound.

45. The method according to claim 44, characterized in that said metal organic compound comprises a metal alkoxide.

35 46. The method according to claim 43, characterized in that both said ion-conducting layer precursor solution and said counterelectrode layer

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precursor solution include at least one metal in the form according to a metal organic or a metal salt compound.

5 47. The method according to claim 46, characterized in that said metal organic compound comprises a metal alkoxide.

10 48. The method according to claim 44, characterized in that said metal of said electrochromic layer precursor solution is selected from the group consisting of tungsten, niobium, titanium, molybdenum, nickel, iridium, and mixtures thereof.

15 49. The method according to claim 46, characterized in that said metal of said counterelectrode layer precursor solution is selected from the group consisting of vanadium, niobium, nickel, cobalt, molybdenum, and mixtures thereof.

20 50. The method according to claim 33, 34 or 35, further characterized by reducing at least one of said electrochromic layer (20) and said counterelectrode layer (24) by inserting said ions thereinto.

51. The method according to claim 50, characterized in that said reducing step is effected during said depositing of said at least one of said electrochromic and said counterelectrode layers.

25 52. The method according to claim 50, characterized in that said ions are selected from the group consisting of lithium and protons.

30 53. The method according to claim 50, further characterized by subsequently subjecting said at least one of said electrochromic layer (20) and said counterelectrode layer (24) to a heat treatment step.

54. The method according to claim 53, characterized in that said heat treatment step is conducted in a vacuum or in an inert atmosphere.

35 55. The method according to claim 53, characterized in that said heat treatment step is conducted at a temperature of greater than about 100°C.

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56. A method for the preparation according to an electrochromic device deposited on a substrate (12) comprising depositing an electrochromic layer (20) acting as a first electrode, depositing a
5 counterelectrode layer (24) acting as a second electrode, and depositing an ion-conducting layer (22) between said first and second electrodes characterized by depositing said ion-conducting layer (22) in the form of an ion-conducting layer precursor solution and
10 effecting gelation of said ion-conducting layer precursor solution by applying said ion-conducting layer precursor solution to said first or second electrode and effecting hydrolysis of said ion-conducting layer precursor solution thereon.

57. The method according to claim 56, characterized in that said applying of said ion-conducting layer precursor solution to said first or second electrode includes removing said substrate (12) from said ion-conducting layer precursor solution at a
20 controlled rate so as to obtain a coating of controlled thickness thereon.

58. The method according to claim 57, characterized in that said hydrolysis step comprises exposing said substrate containing a coating of said
25 ion-conducting precursor solution thereon to a controlled environment.

59. The method according to claim 58, characterized in that said controlled environment comprises a controlled humidity environment.

60. The method according to claim 56 further characterized by heating said hydrolyzed ion-conducting layer precursor solution.

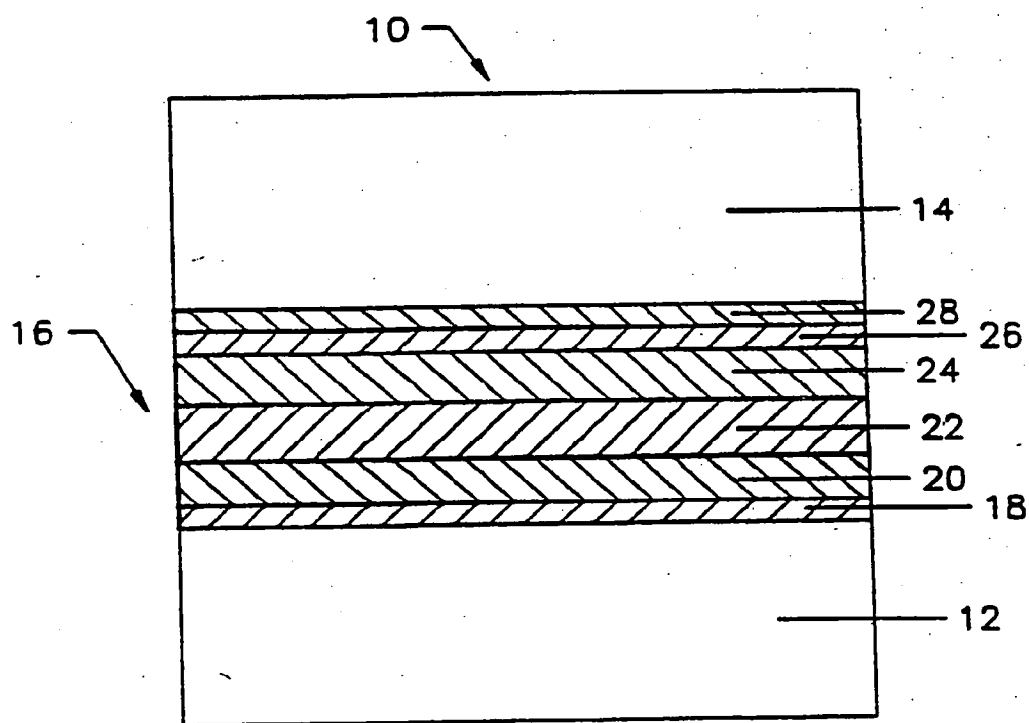


FIG. 1

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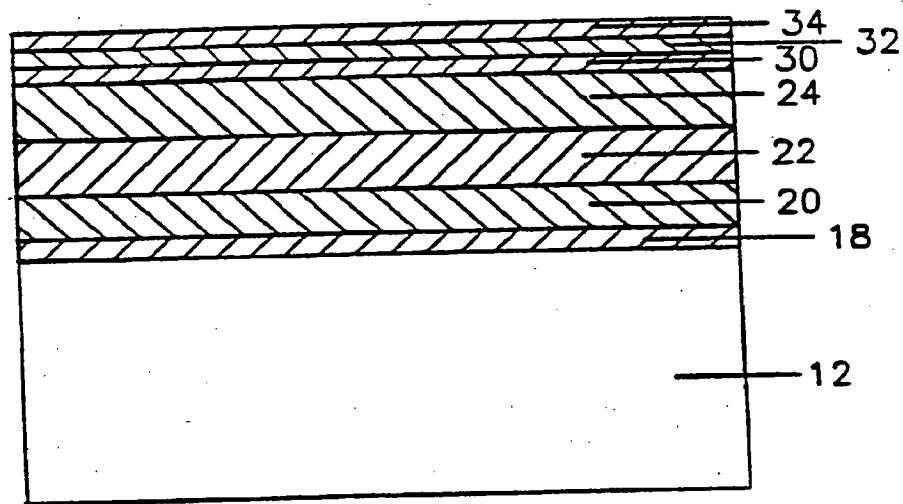


FIG. 2

INTERNATIONAL SEARCH REPORT

PCT/US93/03423

A. CLASSIFICATION OF SUBJECT MATTER

IPC(5) :G02F 1/15, 1/153

US CL :359/265,269,270,275

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 359/265,269,270,275

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

Please See Extra Sheet.

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
<u>X</u> Y	US,A, 4,960,324 (Brown) 02 October 1990 See col. 4, line 8- col. 11, line 49.	1,25,27-29 <u>32</u> 2,3,26,30,31
<u>X</u> Y	US,A, 5,028,124 (Akhtar) 02 July 1991 See col. 2, line 65- col. 4, line 68.	<u>33-35,37</u> 36,38-40
A	US,A, 4,828,369 (Hotomi) 09 May 1989 See entire disclosure.	56-60



Further documents are listed in the continuation of Box C.



See patent family annex.

A	document defining the general state of the art which is not considered to be part of particular relevance	*T*	later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
E	earlier document published on or after the international filing date	*X*	document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
L	document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	*Y*	document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
O	document referring to an oral disclosure, use, exhibition or other means	*Z*	document member of the same patent family
P	document published prior to the international filing date but later than the priority date claimed		

Date of the actual completion of the international search

11 JULY 1993

Date of mailing of the international search report

19 AUG 1993

Name and mailing address of the ISA/US
Commissioner of Patents and Trademarks
Box PCT
Washington, D.C. 20231

Facsimile No. NOT APPLICABLE

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INTERNATIONAL SEARCH REPORT

International application No.

PCT/US93/03423

B. FIELDS SEARCHED

Electronic data bases consulted (Name of data base and where practicable terms used):

APS- Electrochrom?

Counter electrode or counterelectrode

Dissolution

Lithium and Hydrogen

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US93/03423

Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)

This international report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. ☐ Claims Nos.:
because they relate to subject matter not required to be searched by this Authority, namely:
2. ☐ Claims Nos.:
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:
3. ☒ Claims Nos.: 4-24, 41-55
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

1. ☐ As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. ☐ As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. ☐ As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
4. ☐ No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

☐
☐

The additional search fees were accompanied by the applicant's protest.

No protest accompanied the payment of additional search fees.